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The enhanced abrasion resistance of an anti-fingerprint coating on

chrome-plated brass substrate by integrating sputtering and atmospheric

pressure plasma jet technologies

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Abstract

We demonstrate the procedure of fabricating an anti-fingerprint coating on plated-Cr/brass substrates by the combination of two processes: 1) Sputtering and 2) Atmospheric pressure plasma jet (APPJ). APPJ surface treatment on sputtered-SiO_x glue layer on plated-Cr/brass substrate is conducted to improve its surface property to be hydrophilic for chemical bonding with an anti-fingerprint agent (AF-C01). The results show that the surface energy of original substrate are evolving from 44.2 mN/m to 60.8 mN/m and 76.9 mN/m for the sputtered-SiO_x film and APPJ-treated SiO_x film, respectively. Subsequently, the spin-coating process using a commercialnt (AF-C01 agent for the prepared sample is implemented. The hydrophobicity of anti-fingerprint characteristics for all of the samples with a quite low surface energy around 10.5 mN/m are obtained. For practical evaluation of

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